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DENKO K. K. [JP/JP]; 13-9, Shibadaimon 1-chome, Mi-
nato-ku, Tokyo 1058518 (JP).

(72) Inventors; and

(75) Inventors/Applicants (for US only): AOKI, Takanori
[JP/JP]; c/o Production & Technology Control Depart-
ment, Gases & Chemicals Division, Showa Denko K. K.,
5-1, Ogimachi, Kawasaki-ku, Kawasaki-shi, Kanagawa
2100867 (JP). HIRO, Toshitaka [JP/JP]; c/o Production &
Technology Control Department, Gases & Chemicals Di-
vision, Showa Denko K. K., 5-1, Ogimachi, Kawasaki-ku,
Kawasaki-shi, Kanagawa 2100867 (JP).(74) Agent: SUZUKI, Shunichiro; S. Suzuki & Associates,
Gotanda Yamazaki Bldg. 6F, 13-6, Nishigotanda 7-chome,
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(54) Title: PROCESS FOR PRODUCING HYDROXYLAMINE

(57) Abstract: It is an object of the present invention to provide a process for producing a hydroxylamine by reacting a salt of hydroxylamine with an alkali compound, where the yield reduction due to formation of a complex between the produced hydroxylamine and a salt produced as a by-product or adsorption of the hydroxylamine to the by-product salt is decreased, and a high-concentration and high-purity hydroxylamine is safely produced at a high yield. The process for producing a hydroxylamine of the present invention comprises a reaction step of reacting a salt of hydroxylamine with an alkali compound to obtain a hydroxylamine while keeping the reaction solution at a pH of 7 or more, a purification step of purifying the hydroxylamine by ion exchange, and a concentration step of concentrating the hydroxylamine by distillation at the column bottom.

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